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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10085935	03/01/2002	430		1752	

****APPLICANTS:** Takeda Takanobu; Hatakeyama Jun; Ishihara Toshinobu; Kubota Tohru;
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****CONTINUING DATA VERIFIED:**

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**** FOREIGN APPLICATIONS VERIFIED:**
JAPAN 2001-056543 03/01/2001

PG-PUB DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☐ yes ☐ no
35 USC 119 conditions met ☐ yes ☐ no
Verified and Acknowledged Examiners's initials

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KOJIM-448

TITLE : Silicon-containing polymer, resist composition and patterning process

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Assistant Examiner Primary Examiner PREPARED FOR ISSUE	
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Total Claims Print Claim for O.G. Sheets Drwg. Figs. Drwg. Print Fig.	Application Examiner
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